OIPE 408

AMENDMENT TRANSMITTAL LETTER						Docket No. 0171-1100PUS1	
Application No.		Filing Date		Examiner	Art Un		
10/849,186-Conf. #7245		May 20, 2004		J. S. Y. Chu		1752	
10/849,186-Co licant(s): Take ention: BASIC			POSITION A	ND PATTERNING F	PROCES	s	
Amendment nmissioner for F b. Box 1450 xandria, VA 223 ansmitted herev	13-1450	ndment in the	above-identif	ed application.			
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Gerald M. Murp Attorney Reg. N		-# 281781		Dated:	June 14	, 2006	
BIRCH, STEWA 8110 Gatehous Suite 100 East P.O. Box 747	•	H & BIRCH, LI	LP				



Docket No.: 0171-1100PUS1

(PATENT)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:

Takeru WATANABE et al.

Application No.: 10/849,186

ppileation 140.. 10/042,100

Filed: May 20, 2004

For: BASIC COMPOUND, RESIST COMPOSITION

AND PATTERNING PROCESS

Confirmation No.: 7245

Art Unit: 1752

Examiner: J. S. Y. Chu

AMENDMENT IN RESPONSE TO NON-FINAL OFFICE ACTION

MS Amendment Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

INTRODUCTORY COMMENTS

In reply to the outstanding Office Action dated March 14, 2006, the following amendments and Remarks are respectfully submitted in connection with the above-identified application.

This reply includes:

Amendments to the Claims; and

Remarks.